



Masaryk University Brno
Department of Physical Electronics



Atmospheric Pressure Plasmas – Basics and Applications

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Lecture II: Diagnostics of non-thermal atmospheric pressure plasmas

- Electrical characterization
- Optical emission spectroscopy, fast optical/spectroscopic methods
- Surface charge measurements

“Macroscopic” diagnostic



... to be performed AT LEAST on reactors

- Electrical characterization
 - Voltage and current oscillography
 - Power measurements → Specific Energy Density
- Gas analysis (chemistry)
 - Flame Ionization Detection (FID): Total hydrocarbons (THC)
 - Fourier transform infrared spectroscopy (FTIR): IR-active species
 - Gas Chromatography – Mass Spectrometry (GC-MS)

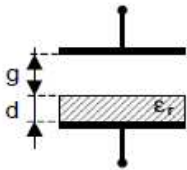
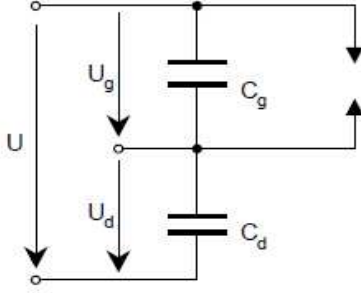
... and if possible

- Optical and spectroscopic methods
 - Optical emission spectroscopy: indirect and average information!
 - Fast imaging: Distribution of MDs → local power density



Electrical characterization of DBDs INP
Greifswald

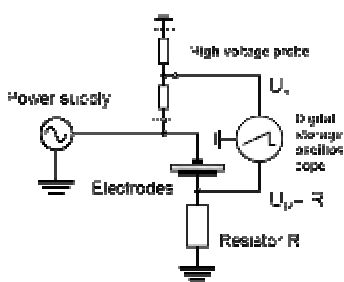
Equivalent circuit (the simplest!)

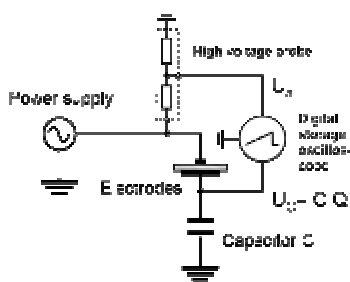
INP
Greifswald

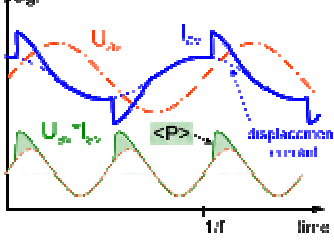
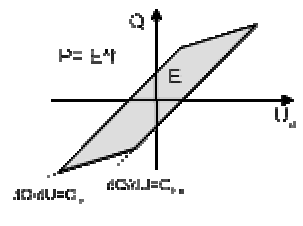
Electrical characterization of DBDs INP
Greifswald

U-I-Oscillography



U-Q-Lissajous figure



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Greifswald

Optical emission spectroscopy

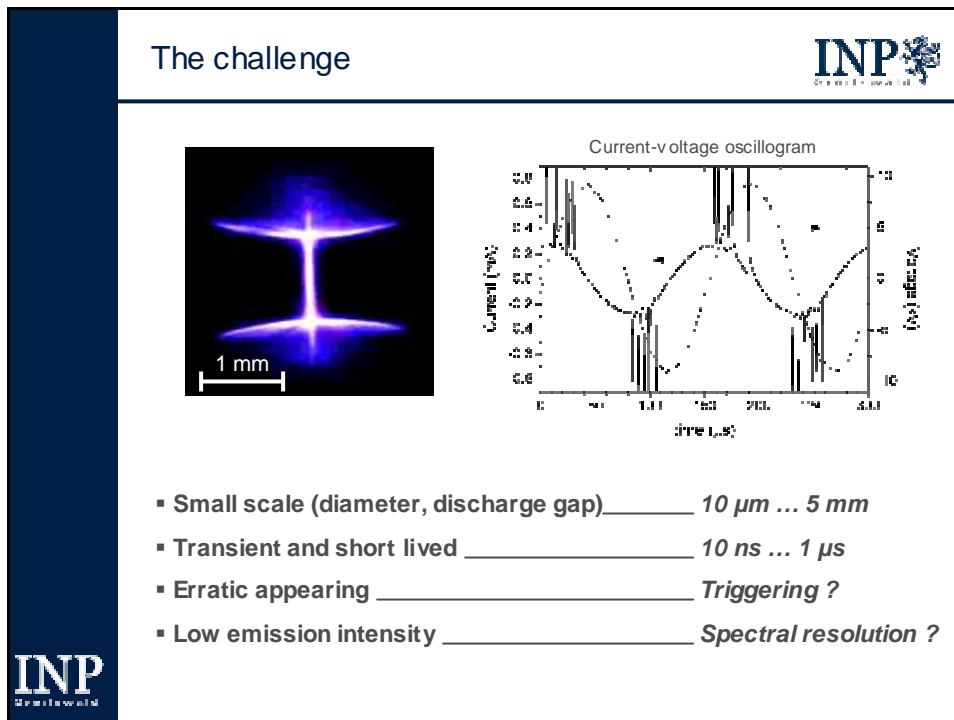
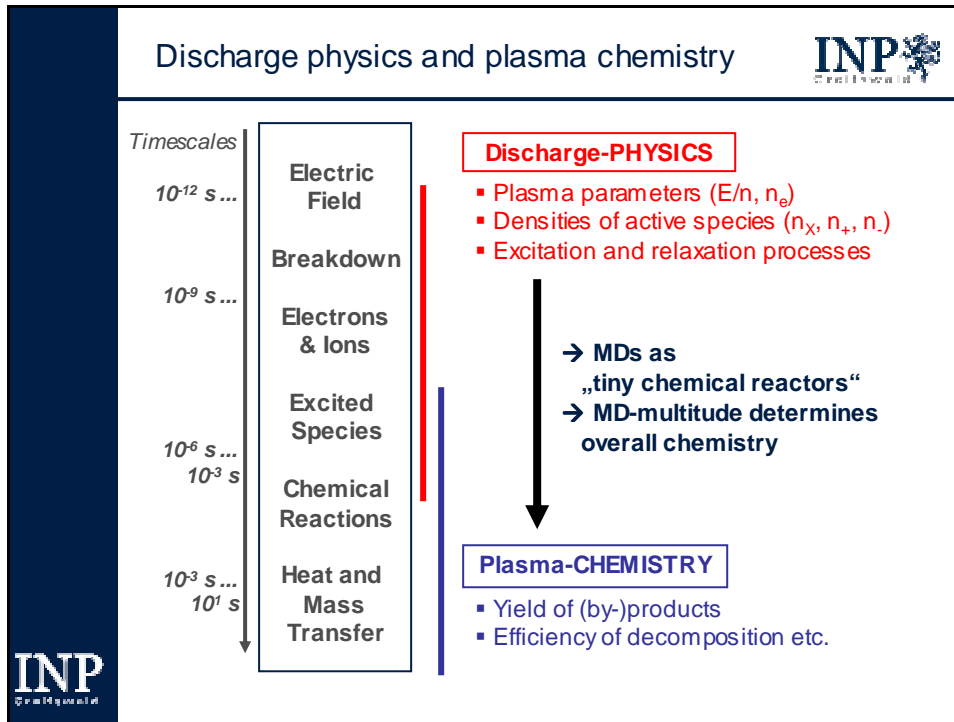
- Simple, non-intrusive
- Emission of plasma (indirect information)
 - gas/excitation temp.
 - electrons (Stark tech.)
- Monitoring of processes
 - intensity
 - spectrum performance

OES sensor system configuration

Filamentary plasmas

- Atmospheric pressure
 - high collision rates (rapid ionization, quenching)
 - streamer breakdown mechanism favoured (Raether/Meeek criterion)
 - small dimensions (Paschen law)

- Electrical breakdown in several individual ionization channels
- Filaments = repetitive, but transient Microdischarges (MDs)



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Methods overview

- Current pulse measurements (Current probes/Rogowski coils)
 - + Mandatory information, but often difficult to measure
 - No spatial information

- Optical and spectroscopic methods
 - + Passive methods, easy to apply, “intuitive”
 - + Independent from gas and discharge type
 - Limited to emission → indirect information

- Laser diagnostics (*LIF, TALIF* → *Volker Schulz-von der Gathen*)
 - + Direct information on density, field, ...
 - Specified diagnostic systems etc.
- Mass spectrometry (*Achim von Keudell, Jan Benedikt*)
 - + Direct and un-specified excess
 - Gas sampling → limited to stable compounds

- Surface charge measurements
 - Quantitative measurement of deposited charges


- Simulation (Fluid, hybrid, ...)
 - Needs experimental verification

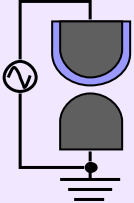
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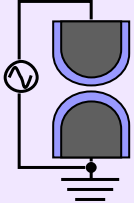
Microdischarge investigation: Single filaments

Volume Barrier Discharge (VBD)






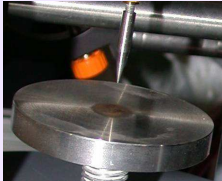
asymmetric

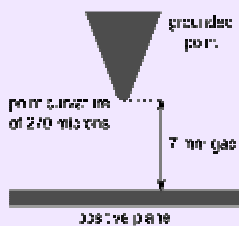


symmetric



Negative Corona Discharge (-CD)



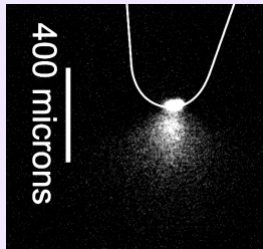


point curvature
of 270 microns

grounded point


7 mm gap

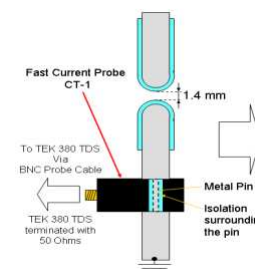
positive plate

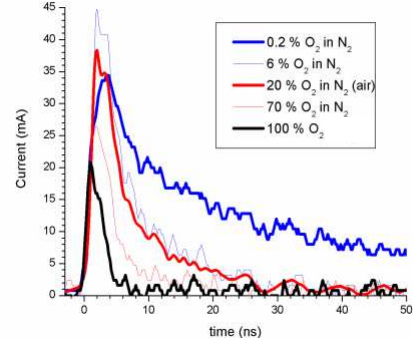


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Fast current measurements








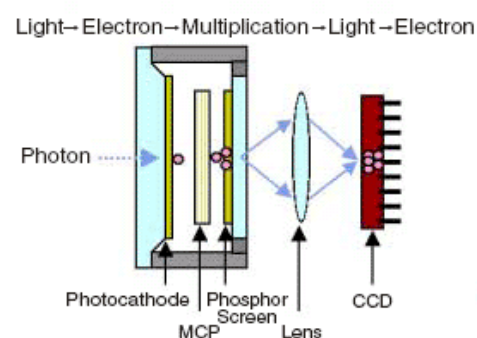
- duration: 1-10 ns
- transported charge: 100-1000 pC
- current density: 100-1000 A cm²



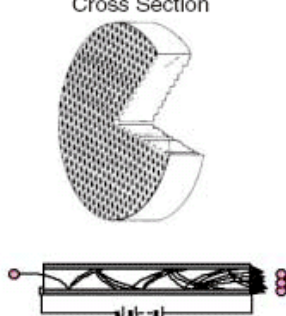
ICCD-camera (short exposure time photos)




Light → Electron → Multiplication → Light → Electron



Micro Channel Plate (MCP)
Cross Section



Principle	Image intensification by micro-channel plate; CCD-Sensor
Parameters	Δt down to 2 ns (new: down to 80 ps, Lavision fast gated ICCD) Gain $10^5 \dots 10^6$
Peculiarities	→ Temporally resolved measurement only if pulsed driven → Photos of individual MDs or discharge channels



Hamamatsu

INP
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ICCD-camera (short exposure time photos)

Volume Barrier Discharge (VBD)

Positive Corona

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T.M.P. Briels et al. J. Phys. D: Appl. Phys. (2008)
 R. Brandenburg et al. J. Phys. D: Applied Phys. (2005)

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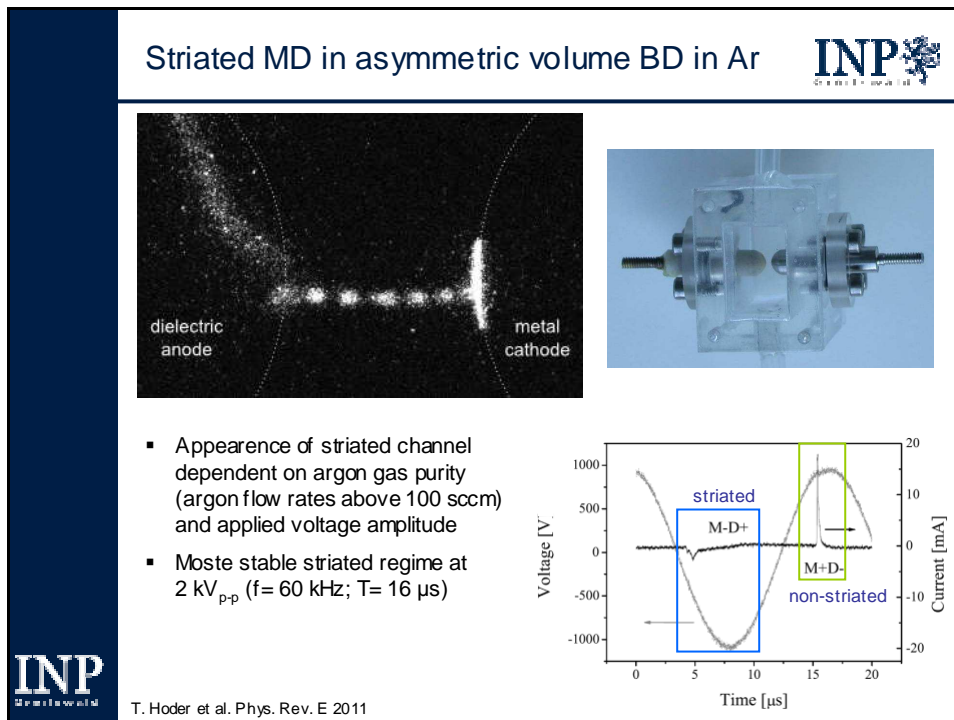
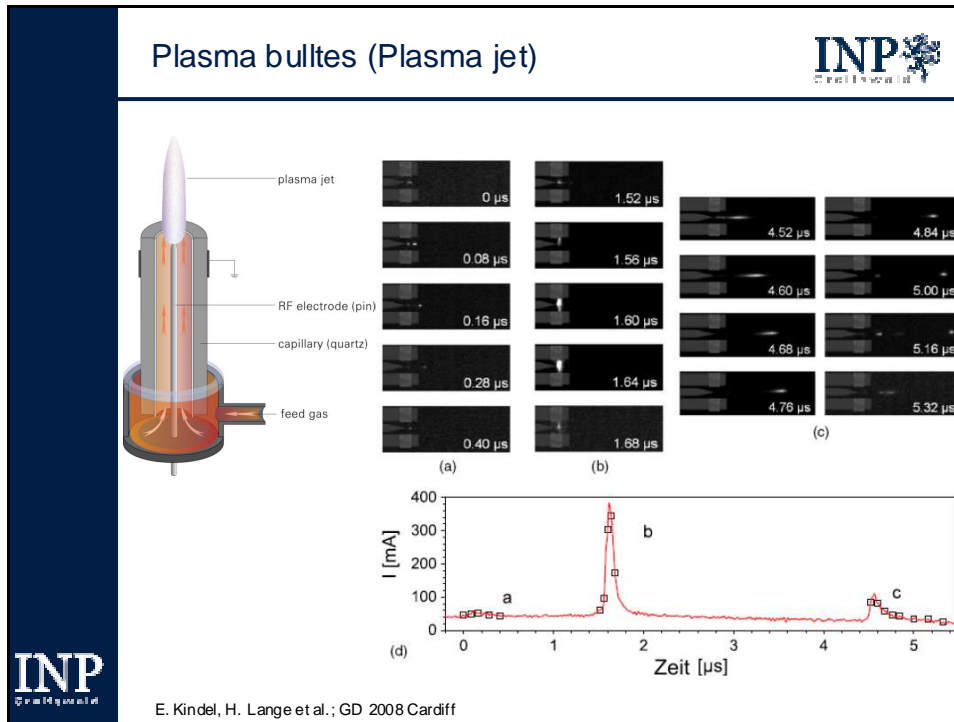
Stereoscopic ICCD-imaging (pos. corona)

Discharge channels analyzed in full 3D


- Reconnection and merging of discharge channels
- Branching angles

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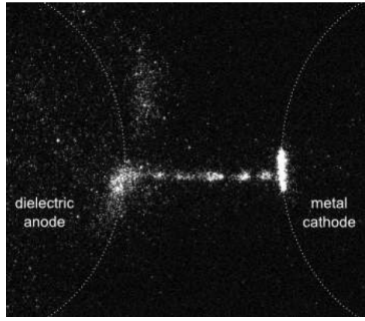
E.M. van Veldhuizen et al. Eur. Phys. J. - Appl. Phys. 47, 22811 (5p) (2009)



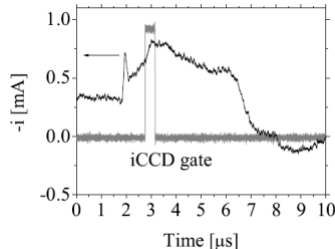
Reconstruction of temporal development



- Simultaneous recording of current and ICCD-photo (gate-signal)
- “Sorting” of ICCD-photos according to relation between ICCD-gate and current pulse



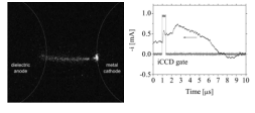
dielectric anode metal cathode

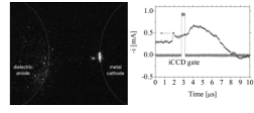


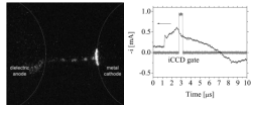
$-i$ [mA]


iCCD gate

Time [μ s]








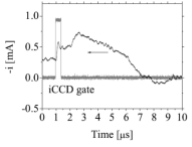


Spatio-temporally resolved development



1. glow-discharge-like structure
2. striated column and extended cathode layer
3. striated structure decay towards cathode

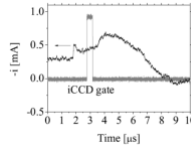
time ➔



$-i$ [mA]

iCCD gate

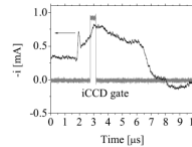
Time [μ s]



$-i$ [mA]

iCCD gate

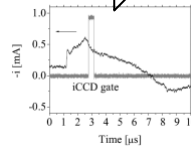
Time [μ s]



$-i$ [mA]

iCCD gate

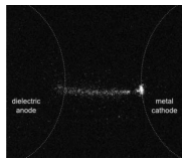
Time [μ s]



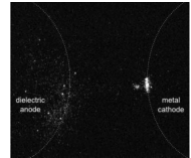
$-i$ [mA]

iCCD gate

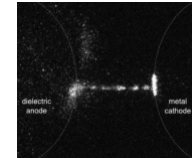
Time [μ s]



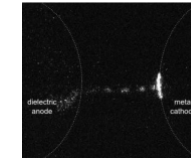
dielectric anode metal cathode




dielectric anode metal cathode




dielectric anode metal cathode



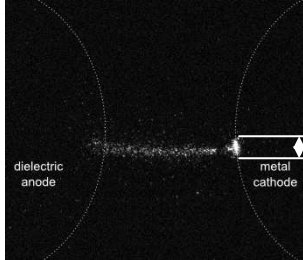
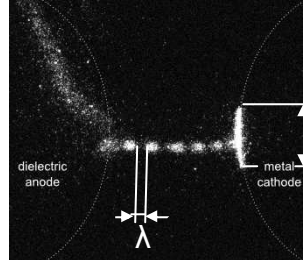
dielectric anode metal cathode




MD striation mechanism




- Scaling parameters from scaling law theory for low pressure discharges:
 $i = 0.8 \text{ mA}$, $r = 60 \text{ }\mu\text{m}$, $\lambda = 200 \text{ to } 300 \text{ }\mu\text{m}$
 $\rightarrow i/r \approx 13 \text{ A/cm}$, $p \cdot r = 5 \text{ Torr}\cdot\text{cm}$, $3 \leq \lambda/r \leq 5$
Similar to striations in low pressure glow discharges
- Different diameter of the cathode layer - channel constriction
 \rightarrow different current densities at the cathode layer and in the channel
 \rightarrow electron density gradient \rightarrow local disturbance & **spatial electron relaxation**
- Energy dissipation length $\lambda_e(U) = 196 \text{ }\mu\text{m}$ (theory*) corresponds to distance between the neighboring striations λ

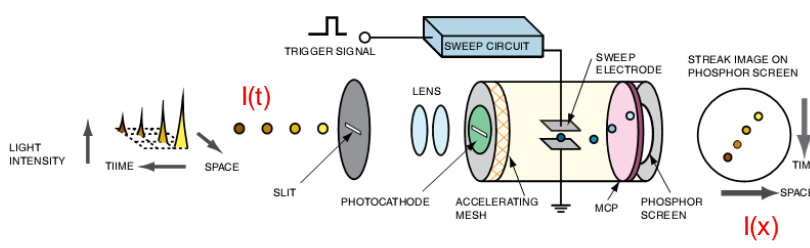



*D. Loffhagen, M. Becker; INP Greifswald




Streak camera (optoscope)





Principle	Temporal profile transformed into spatial profile by defined deflection in streak tube and (I)CCD
Parameters	Δt down to 1 ps Gain $10^5 \dots 10^6$
Peculiarities	\rightarrow Temporally resolved investigation of individual MDs \rightarrow One spatial dimension



Hamamatsu

Streak photos of positive coronas

Marode 1974

Sigmond 1983

Eichwald 2008

- Primary streamer (ps) and secondary streamer (ss)
- Return stroke (return streamers) and spark (S) formation

E. Marode; Journal of Applied Physics, Vol. 46, No.5 (1975); Raizer "Gas discharge physics" (Springer)
 O. Eichwald et al.; J. Phys. D: Appl. Phys. 41 (2008) 234002 R.S. Sigmond; J. Appl. Phys. 56 (5),1 (1984)

Streak photos in volume BD

Air


Optical streak

Kr/He/Cl₂ @ 400 mbar

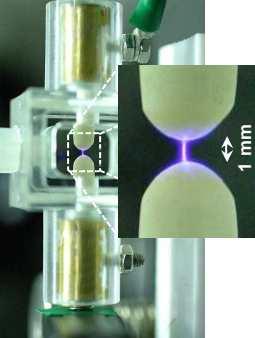
Electro-Optical streak

C. Heuser, Diss. RWTH Aachen; G. J. Pietsch, Contributions to Plasma Physics 41, 620-628 (2001);
 R.-J. Zahn S. Müller, 8th Int. Symposium on Science & Technology of Light Sources, Greifswald (1998).

Pulsed driven volume BD in N₂/O₂

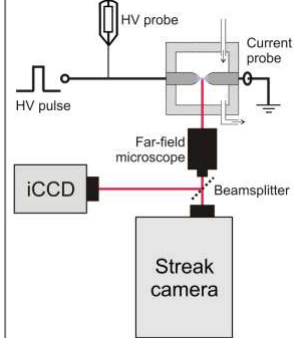


Discharge cell




- Dielectric: Al₂O₃ ($\epsilon_r \approx 9$), about 0.5 mm thick
- „Square wave“ HV-pulses:
 $U_p = 7 \dots 10$ kV;
 $dU/dt \sim 250$ V/ns;
 $f = 10$ kHz

Diagnostics




- Simultaneous measurement with ICCD and streak camera
- Electrical diagnostics



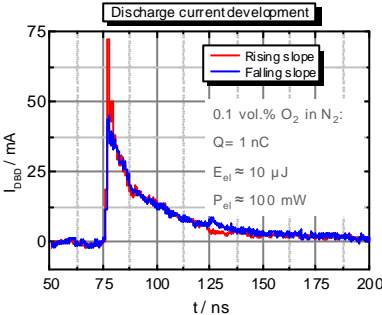
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Electrical measurements




Voltage
Current

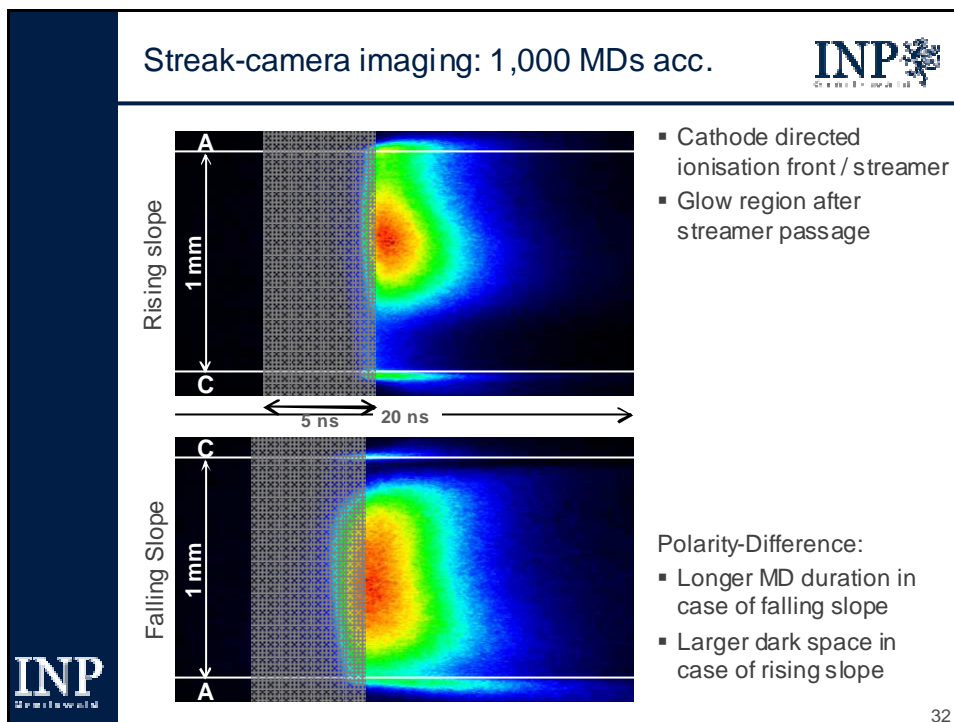
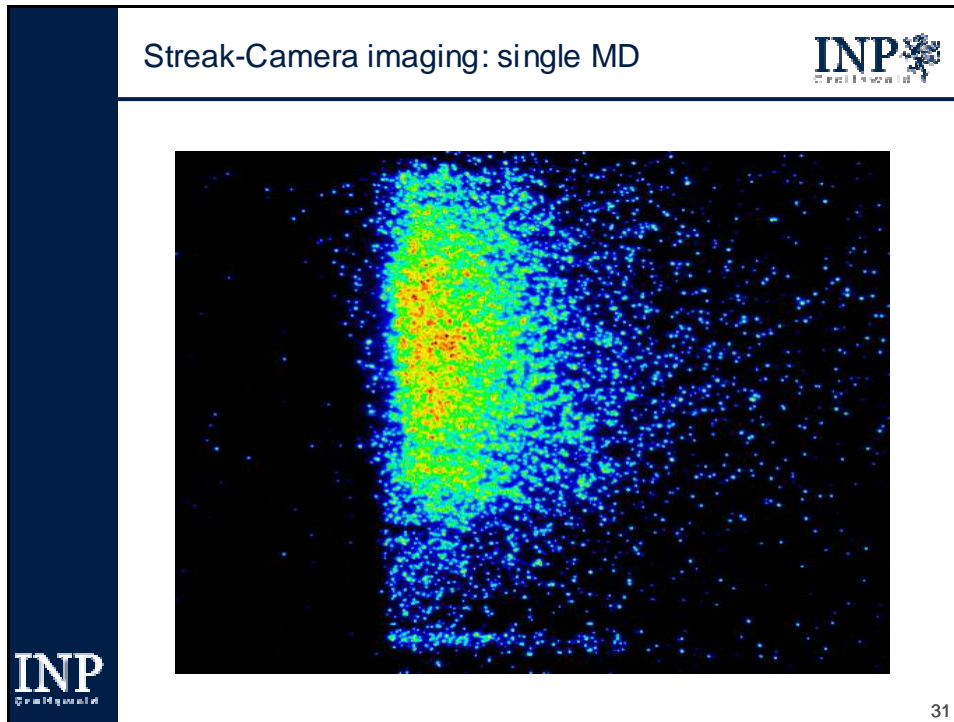
Discharge current development

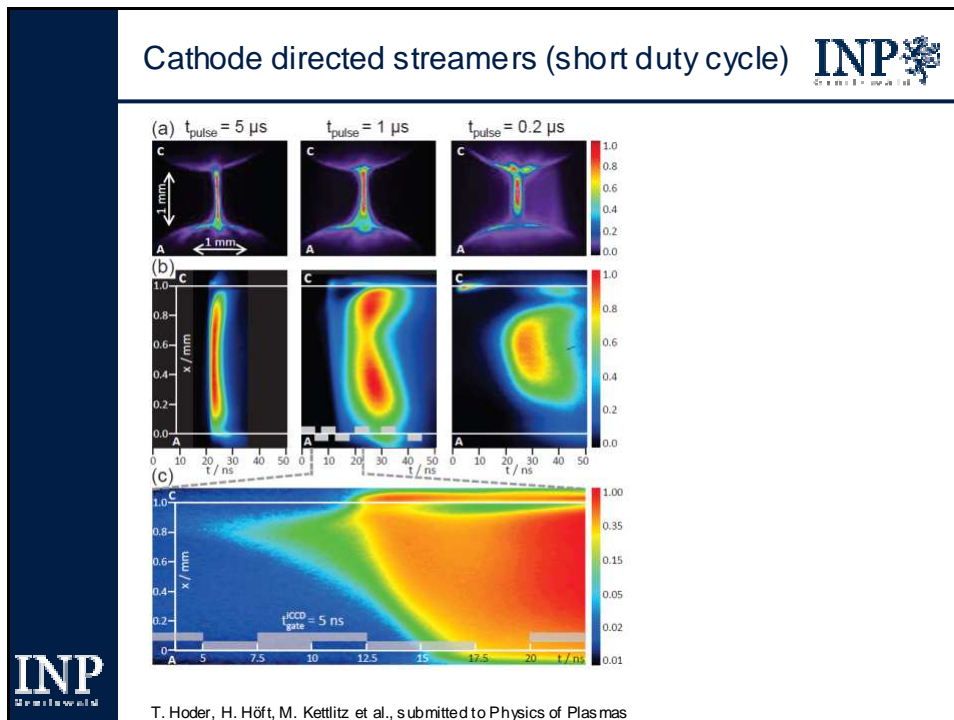
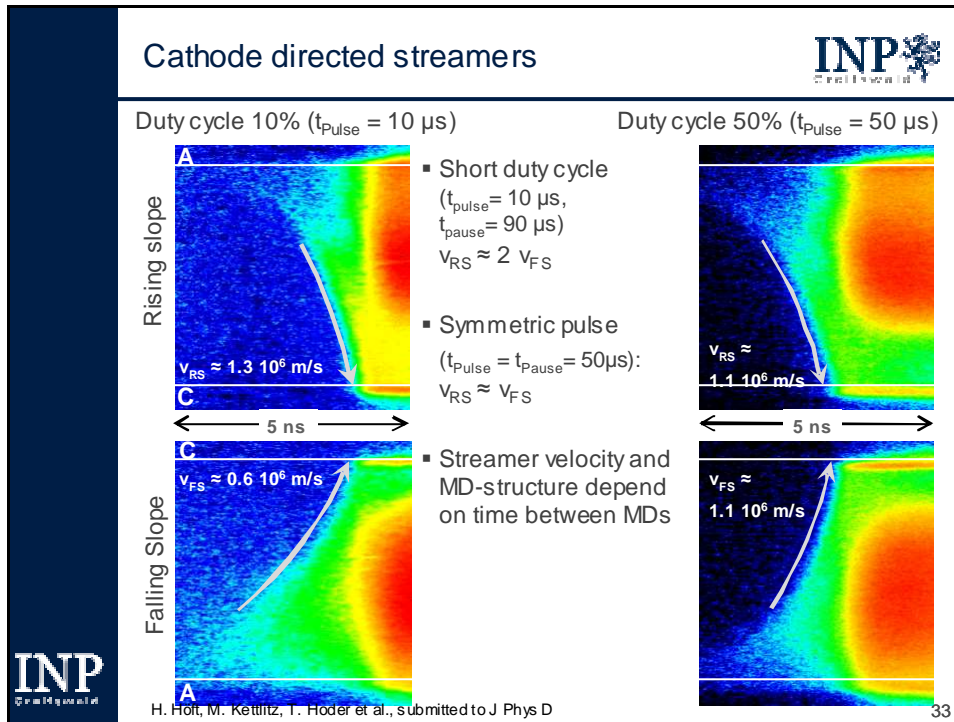


- One MD in the rising and in the falling slope of pulsed high voltage
- Similar current pulses at both slopes
- Decreases current pulse amplitude and duration with increasing [O₂]




30







Cross-Correlation Spectroscopy (CCS)




Principle	Time-correlated single photon counting (TC-SPC) with reference signal from MDs itself
Parameters	Δt down to 12 ps Gain up to 10^8 $\Delta \lambda$ about 0.03 nm
Peculiarities	→ highest sensitivity → temporally and spectrally resolved investigation of repetitive, but erratic appearing discharge events → averaging over many MDs (stability required) → 2D spatial resolution possible




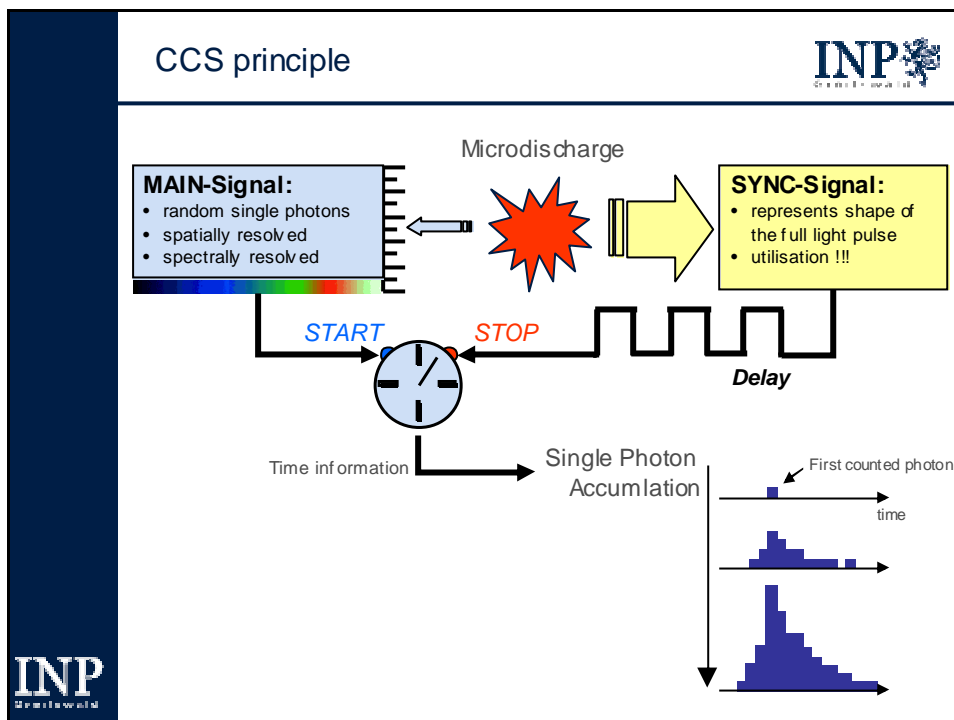
High Gain
Photomultiplier (PMT)




TC-SPC Board

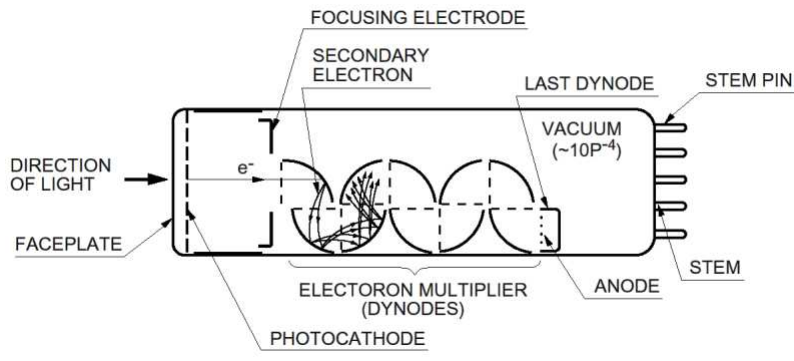







High-Gain Photomultiplier






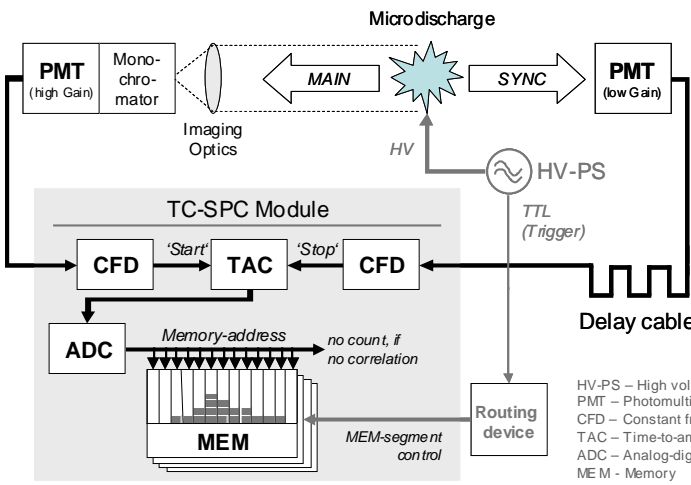
Gain of up to 10^8




W. Becker, Becker-Hickl GmbH Berlin

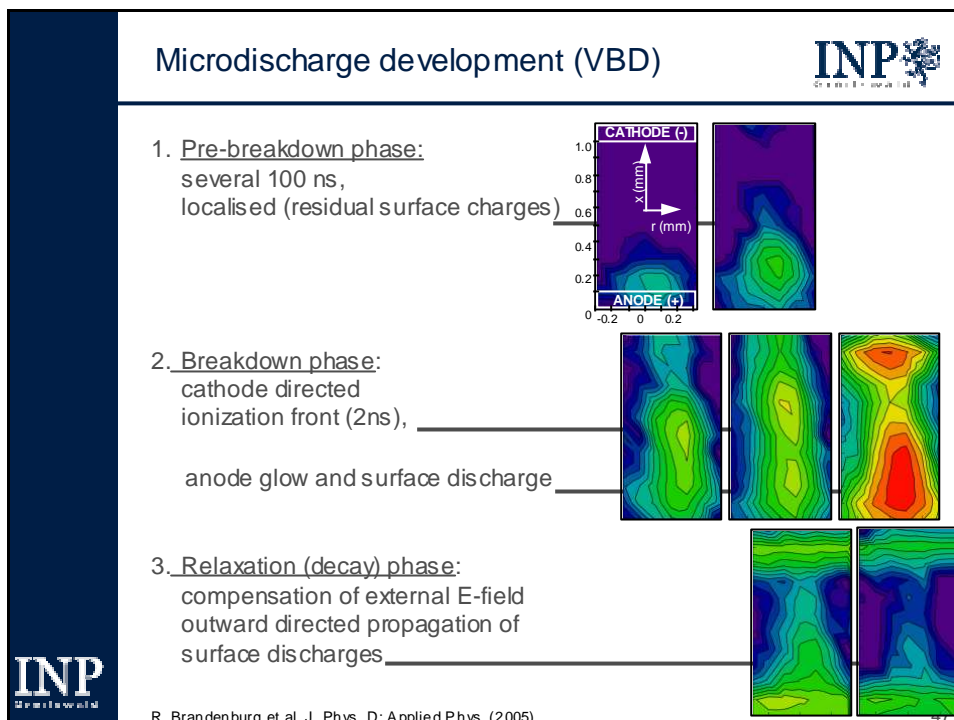
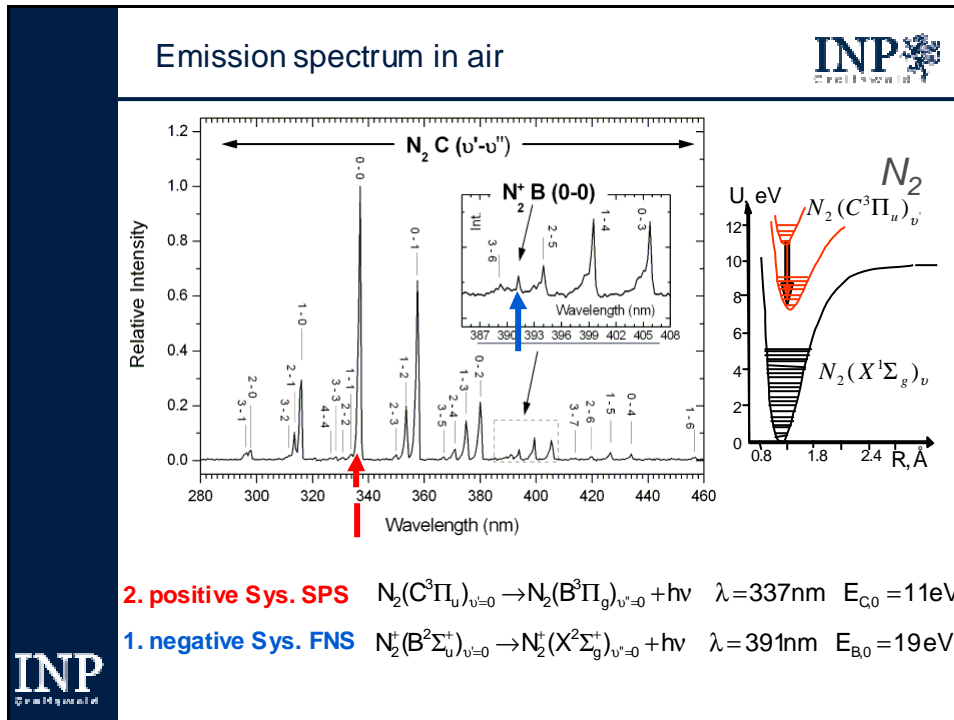
CCS set-up

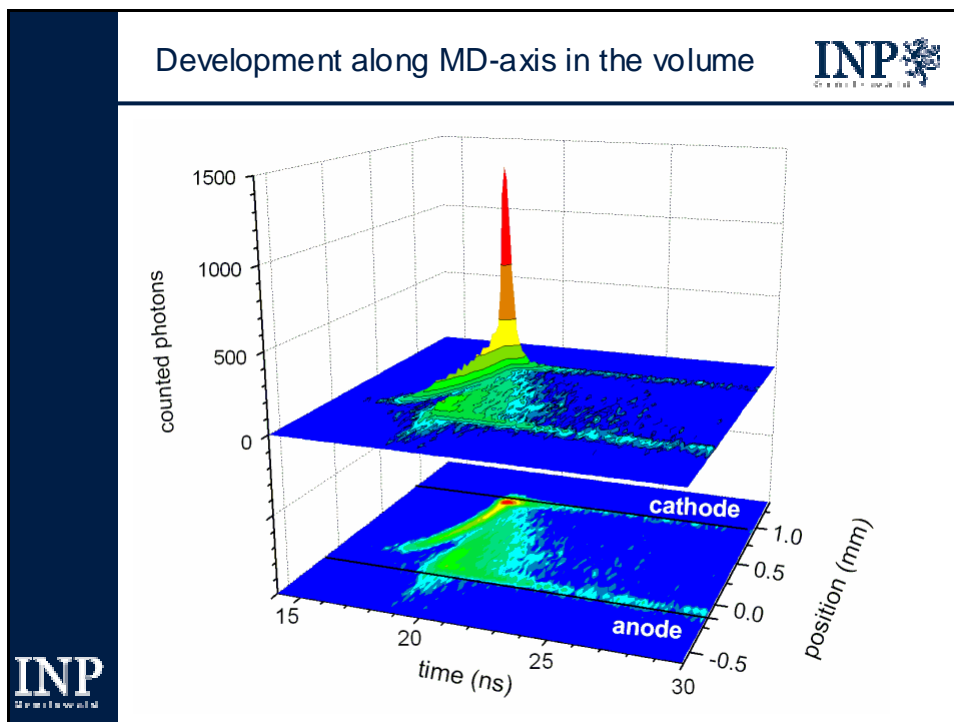
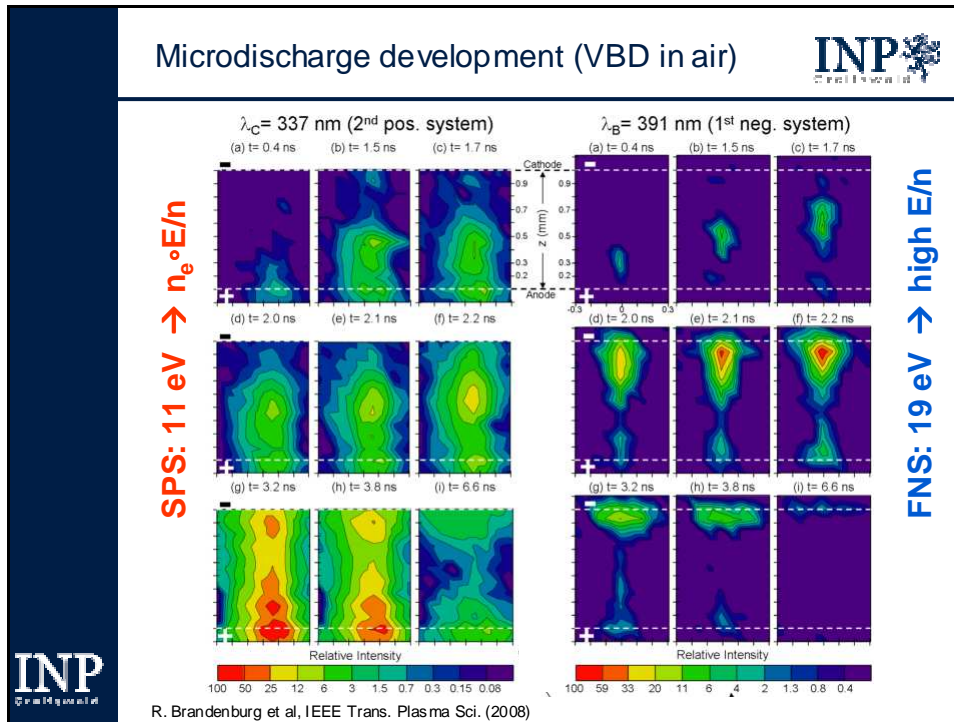


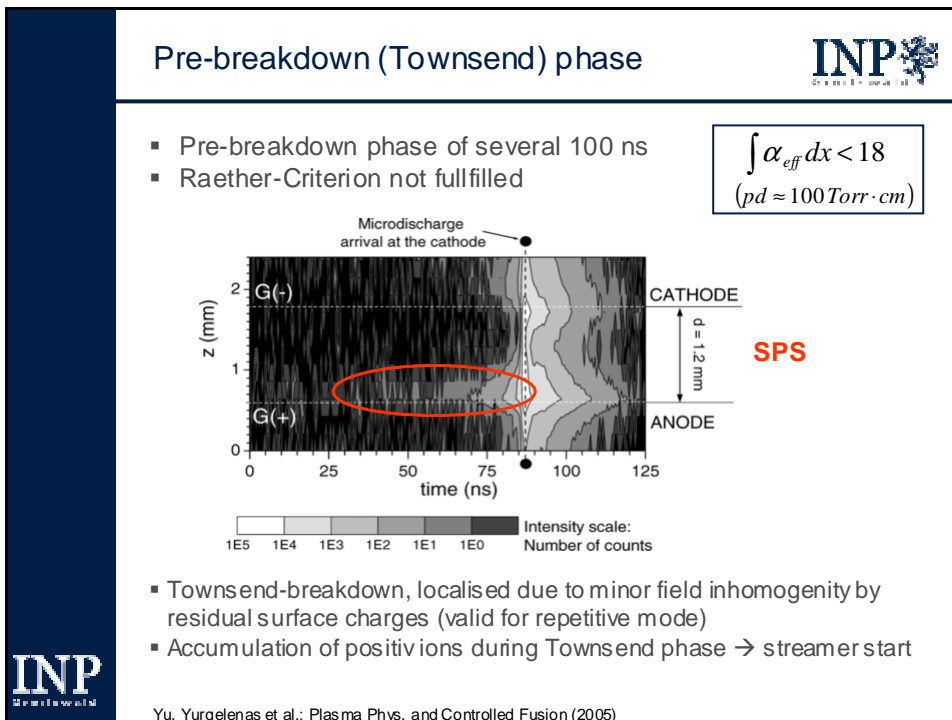
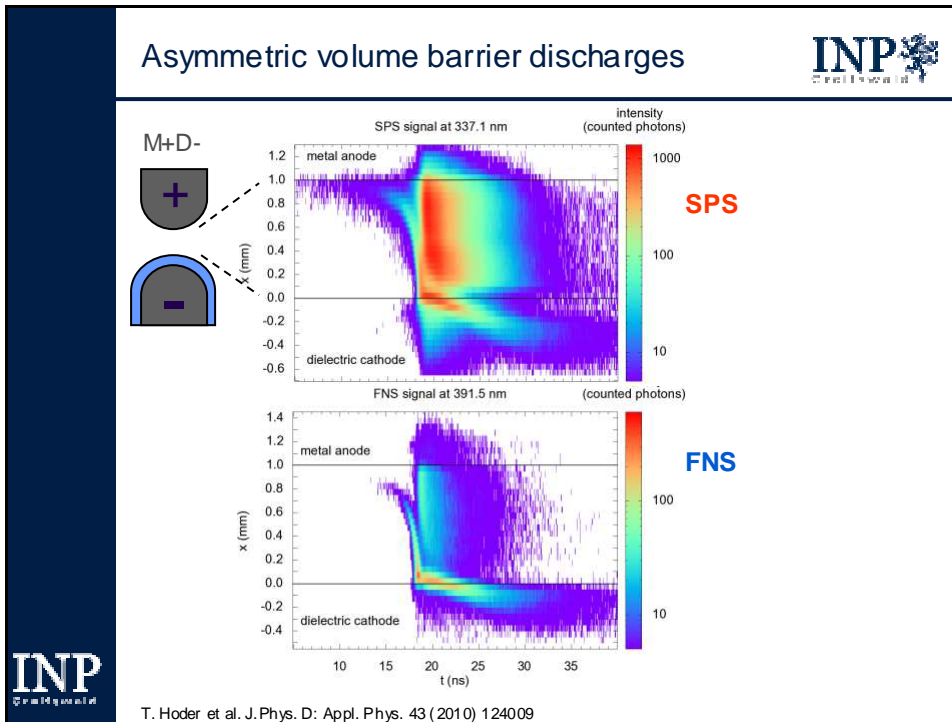


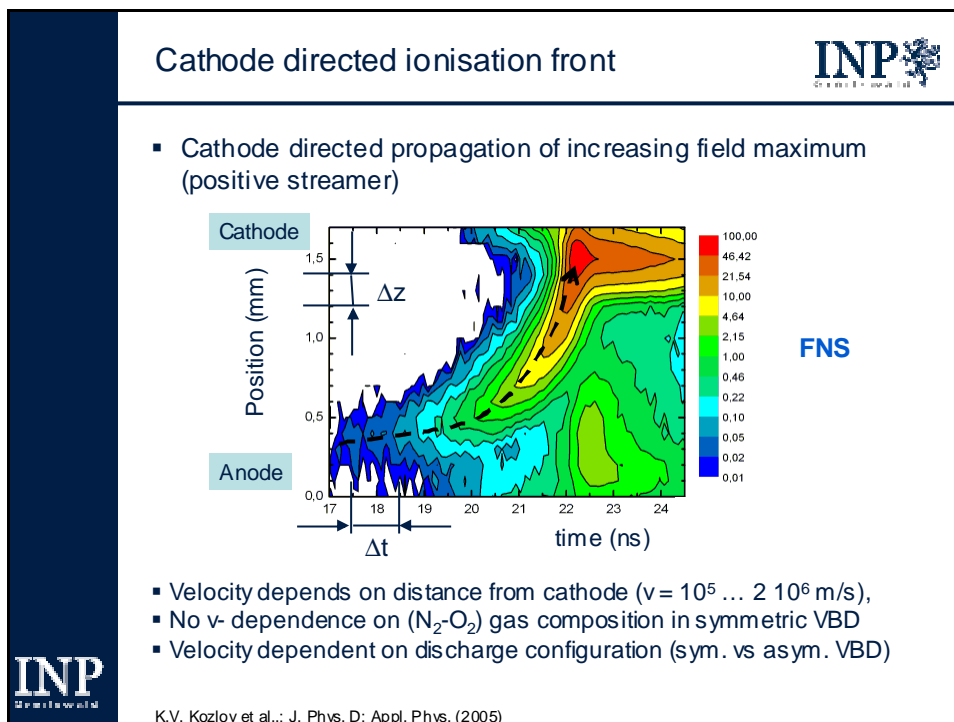
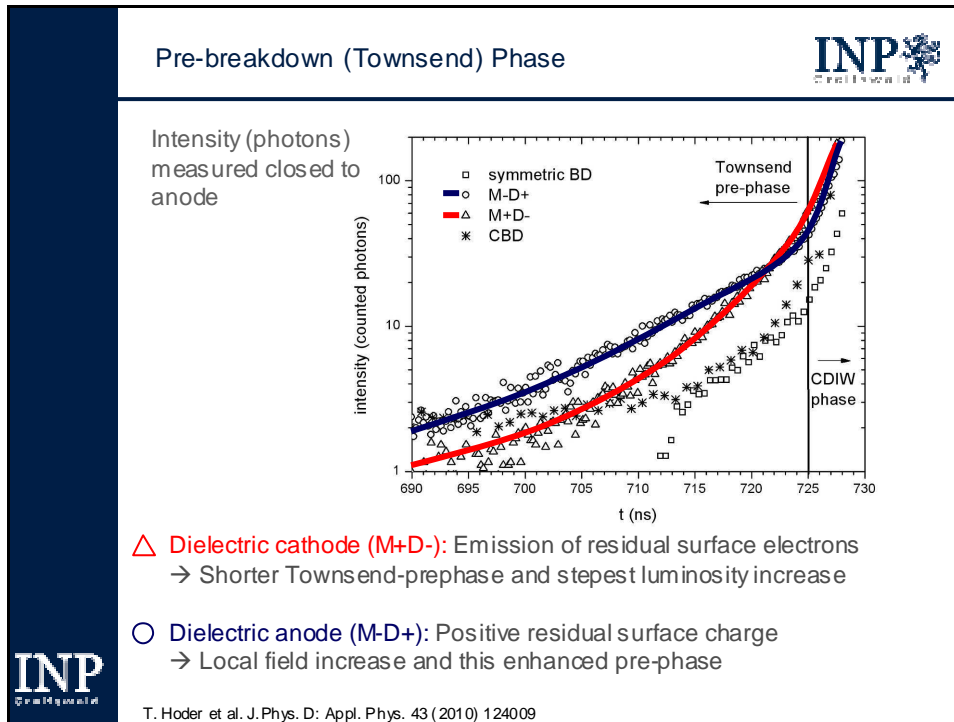
- HV-PS – High voltage power supply
- PMT – Photomultiplier
- CFD – Constant fraction discriminator
- TAC – Time-to-amplitude converter
- ADC – Analog-digital converter
- MEM – Memory

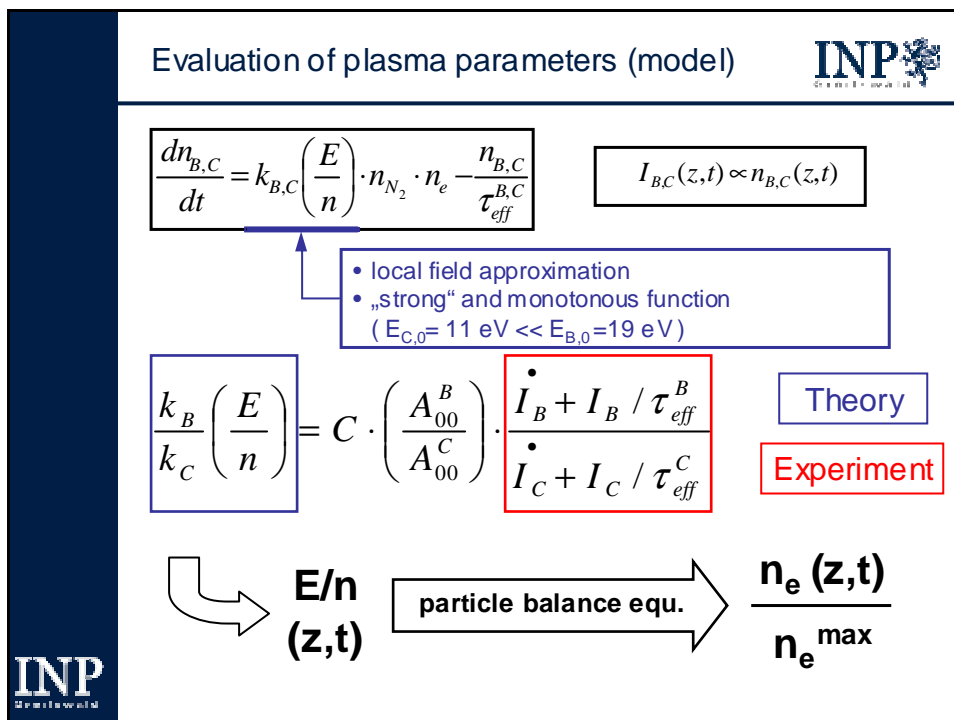
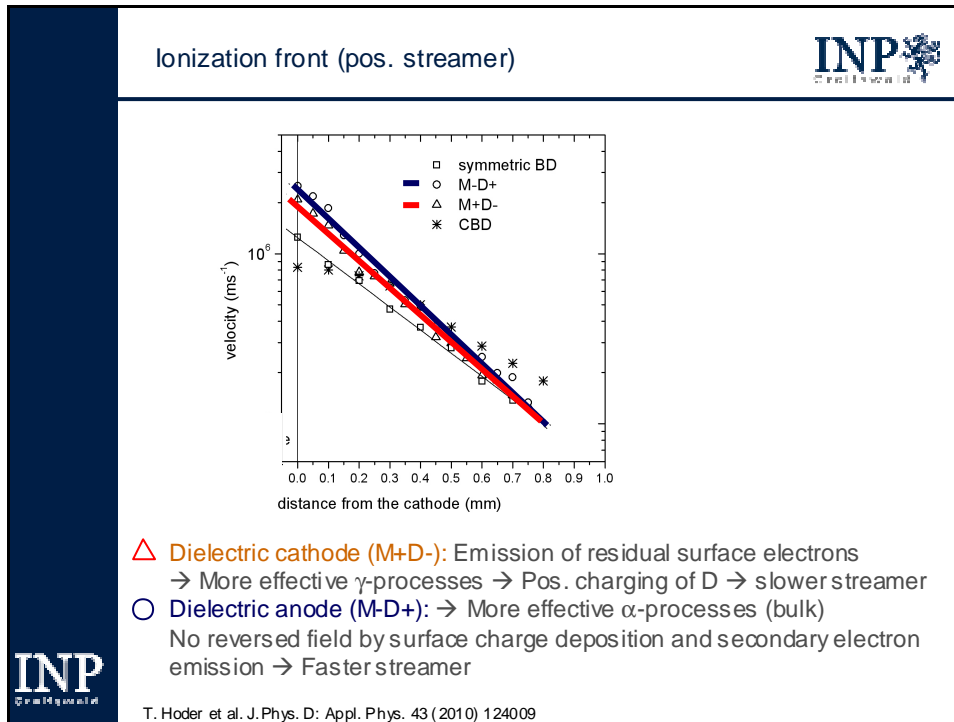


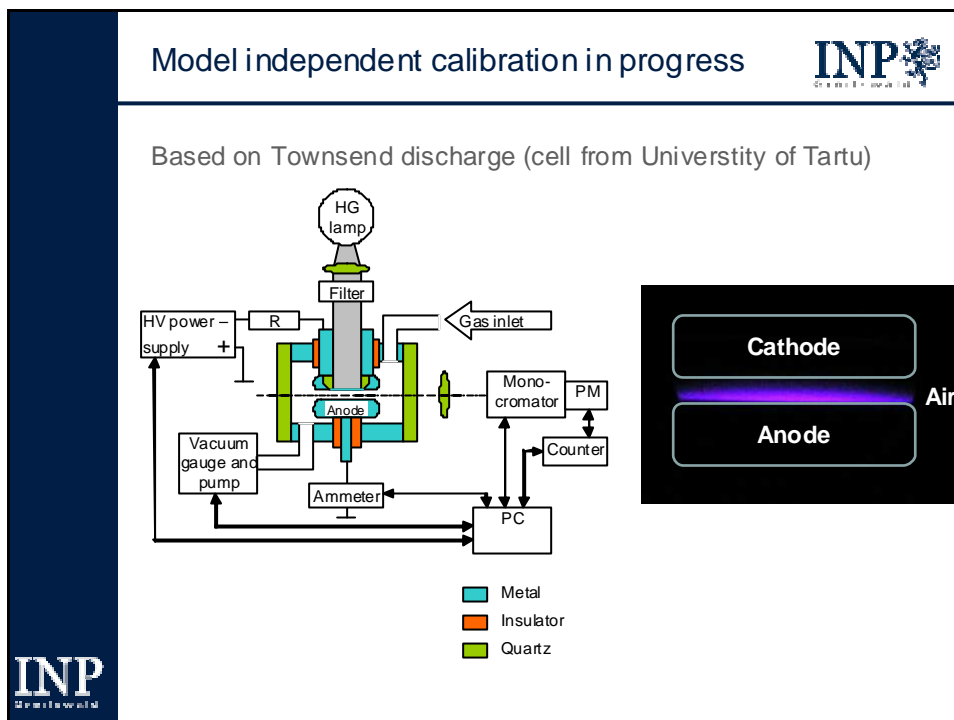
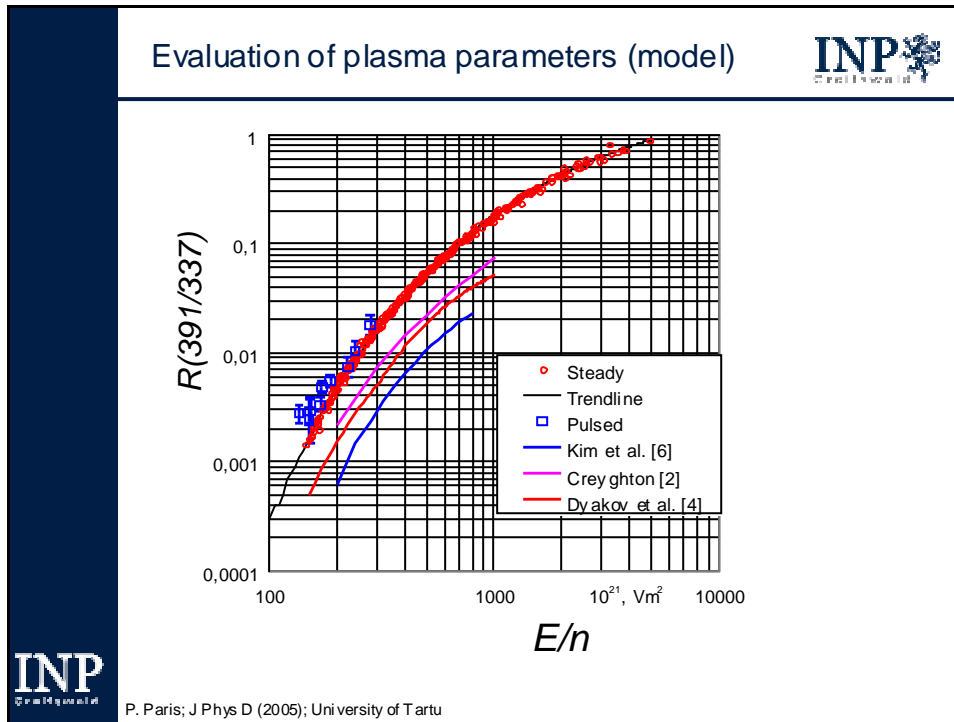


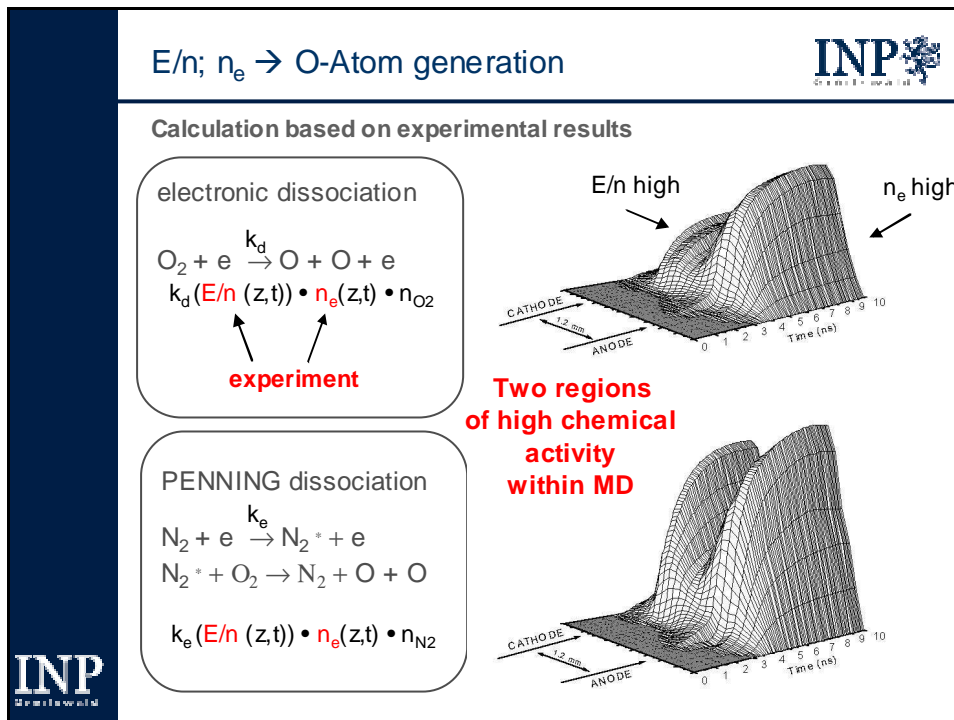
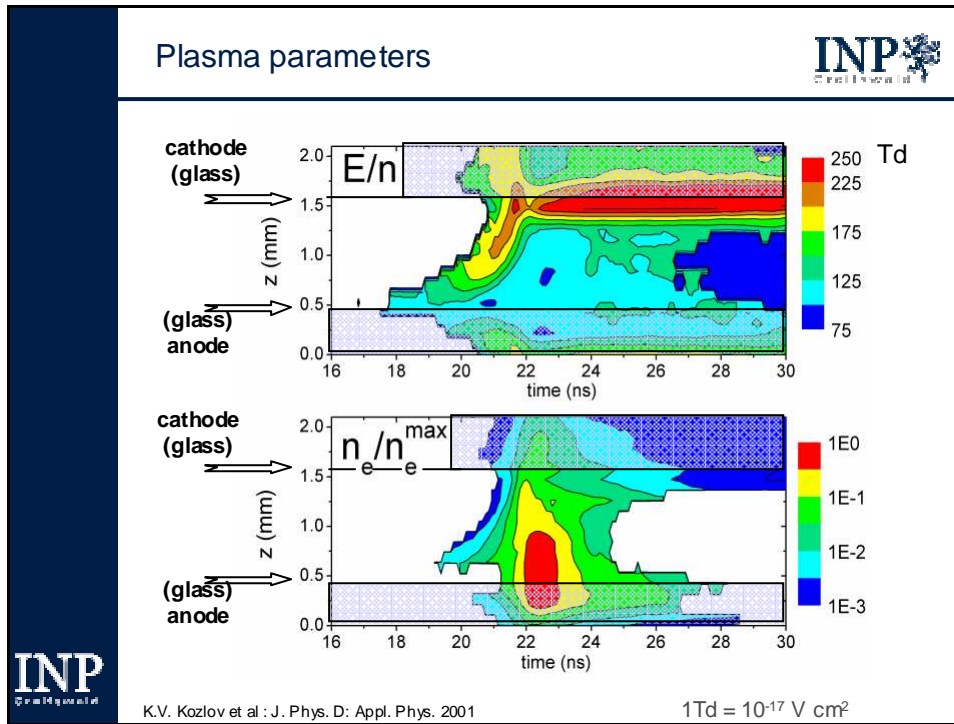


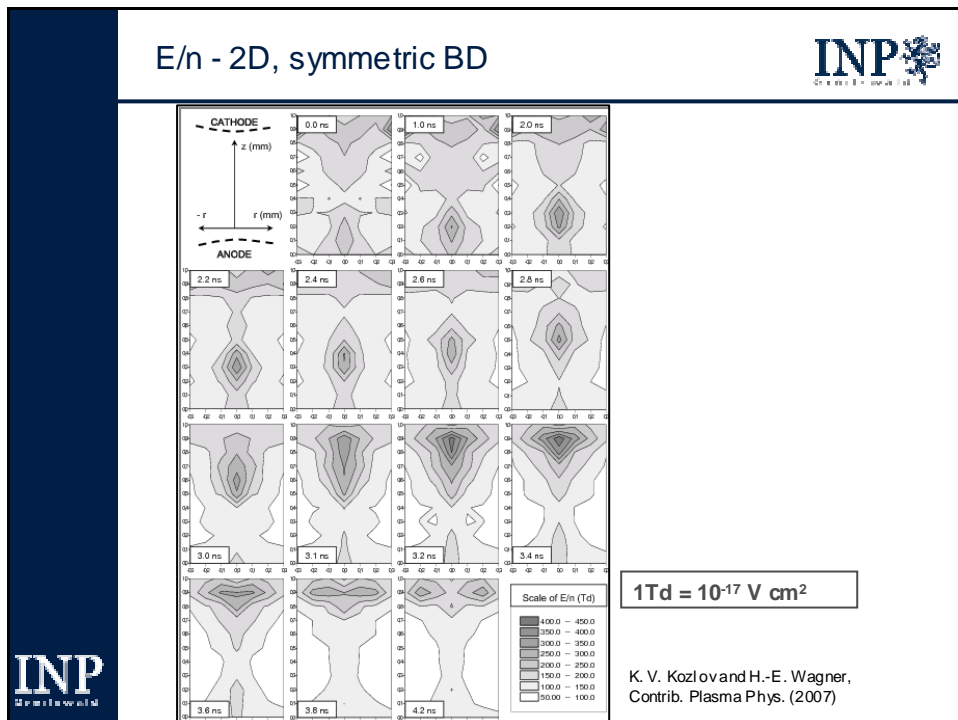
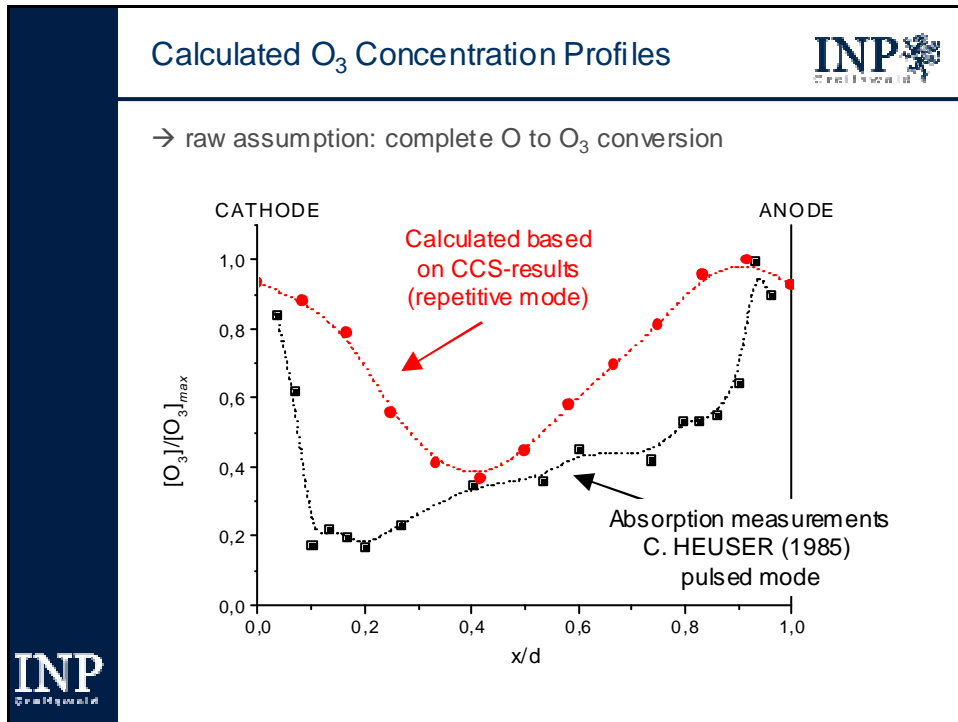













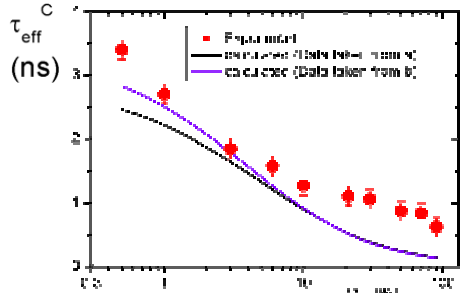
Time constants



▪ In regions of relaxing plasma:
 decay process for estimation of effective lifetimes

$$\frac{1}{\tau_{\text{eff}}^C} = \frac{1}{\tau_{\text{rad}}^C} + K_{\text{N}_2}^C n_{\text{N}_2} + K_{\text{O}_2}^C n_{\text{O}_2}$$


← Quenching!




$$K_{\text{N}_2}^C \ll K_{\text{O}_2}^C$$

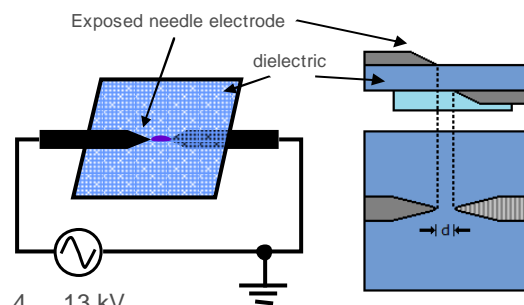
a) Pancheshnyi et al., Chem Phys. 262 (2000) 349;
 b) Mitchell, J. Chem Phys. 53, 5 (1970) 1795

K.V. Kozlov et al : J. Phys. D: Appl. Phys. 2005



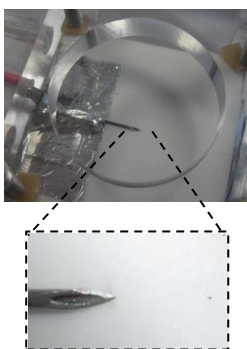
SBD configuration for MD studies






Exposed needle electrode
dielectric

4 ... 13 kV_{pp}
 ~ 60 kHz




→ Localization & stabilization for time-consuming CCS measurements

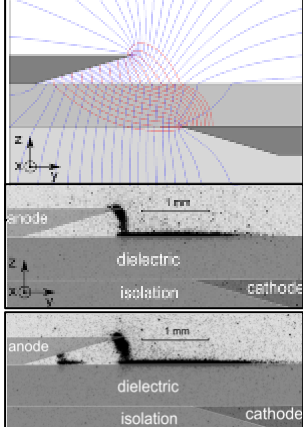
- Two needle electrodes (Ø 0,4 mm, chrome- nickel- steel- alloy)
- Elektrode gap d= 1.15 mm
- Dielectric material: Al₂O₃, 0.6 mm thickness
- Gas: dry air



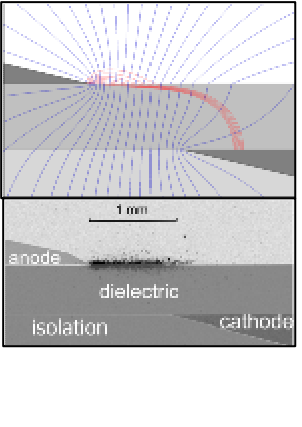
Discharge generation



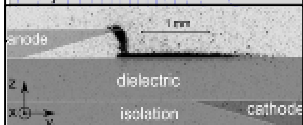
Field configuration: Calculated **stream lines** and **potential**




Volume discharge and surface discharge



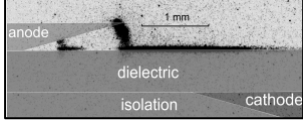
Surface discharge




anode
dielectric
isolation
cathode



anode
dielectric
isolation
cathode




anode
dielectric
isolation
cathode

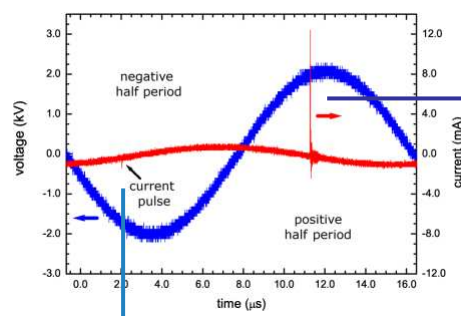


T. Hoder, H. Grosch et al., EPJD 2010; IEEE Trans. Plas. Sci. 2011

Surface Barrier Discharges (SBD)

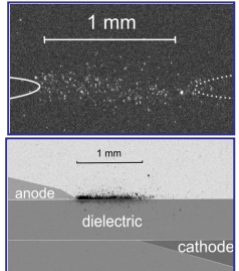


Applied Voltage closed to burning voltage → one MD per half period (HP)



negative half period
current pulse
positive half period

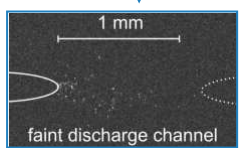
voltage (kV)
current (mA)
time (μs)



1 mm

anode (exposed)
dielectric
cathode (covered)

Exposure time: 8,5 μs



1 mm

faint discharge channel

cathode (exposed)
anode (covered)


Exposure time: 8,5 μs

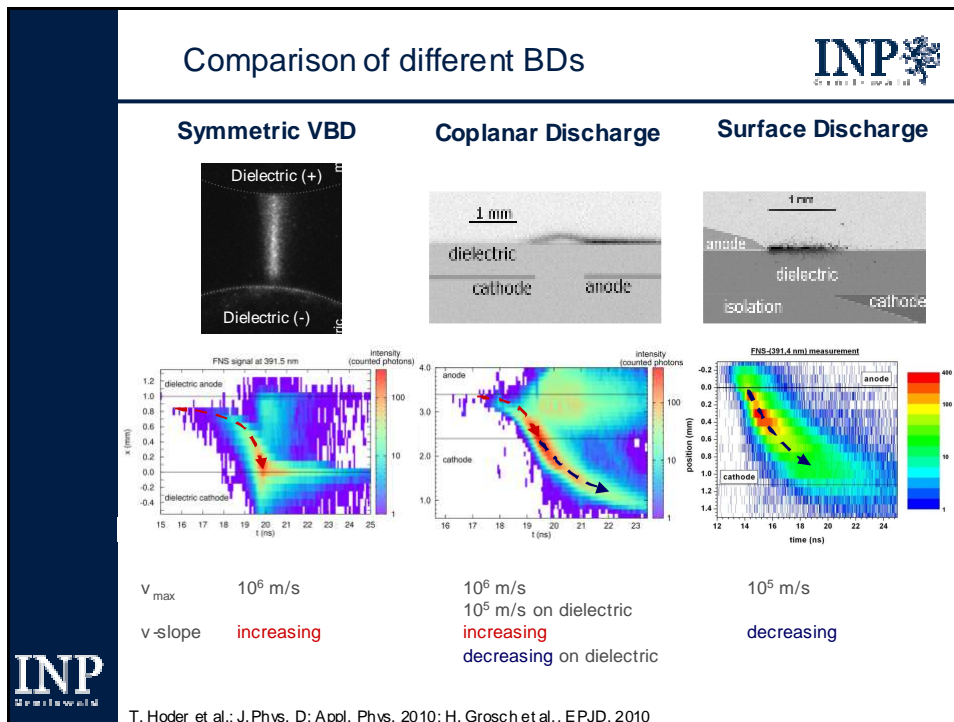
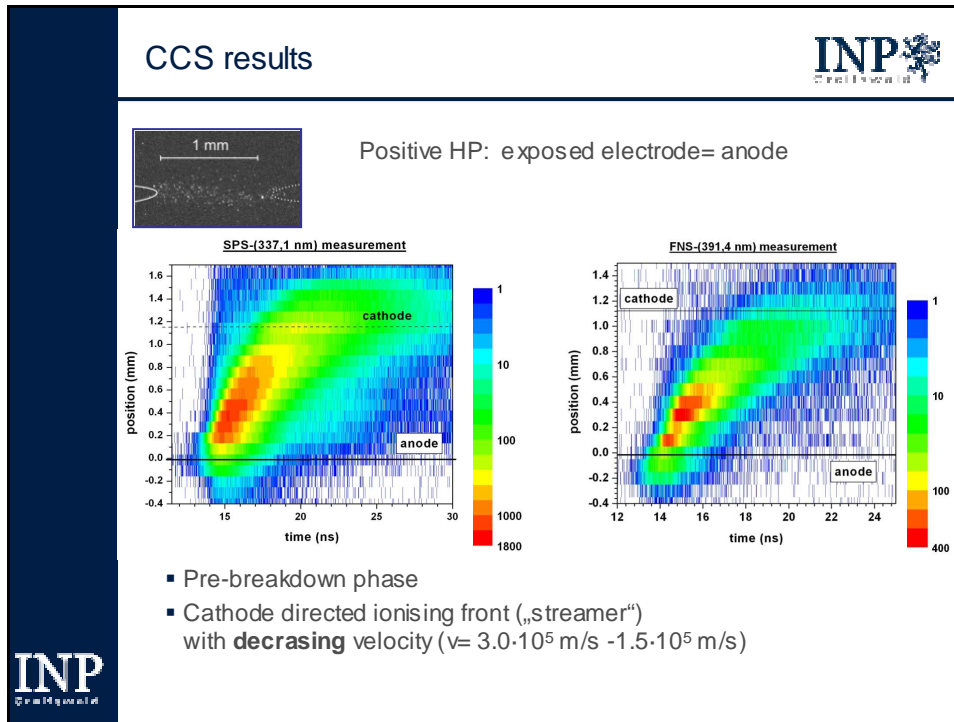
Negative half period

- faint discharge activity at the tip of cathode


Positive half period

- Amplitude range: 2 mA - 40 mA
- Average amplitude: ~ 12 mA
- Average rise time: ~ 2 ns

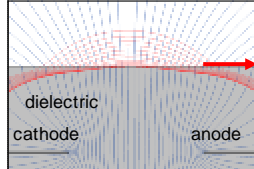




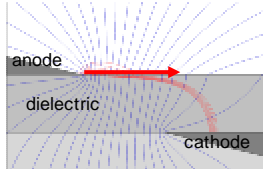
MD propagation on dielectric barrier



Coplanar Discharge



Surface Discharge



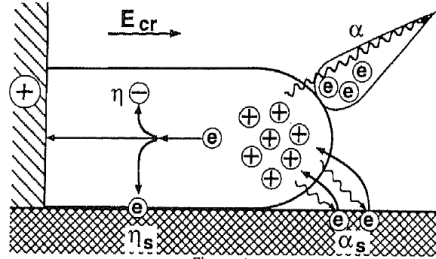
External electric field:


- decreases along MD path

Red: Streamlines
 Blue: Equipotential lines

Surface processes:


- negative residual charge (e^-)
- surface ionization α_s (detrapping, photo effect, ion impact)
- surface attachment η_s



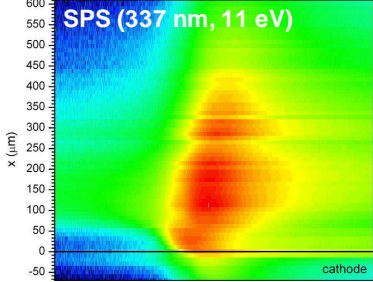


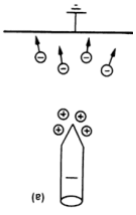
Niemeyer, L.; IEEE Trans. Dielectr. Electr. Insul. (1995), Vol. 2 No.4, 510-528

Trichel pulse corona (negative corona)

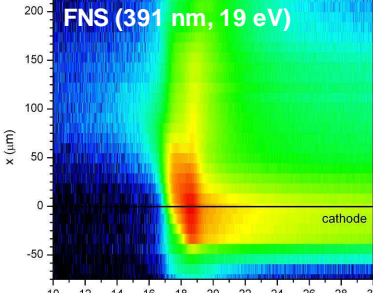


SPS (337 nm, 11 eV)







FNS (391 nm, 19 eV)



1. Electron multiplication phase (120 μm)
2. pos. streamer
3. anode directed streamer

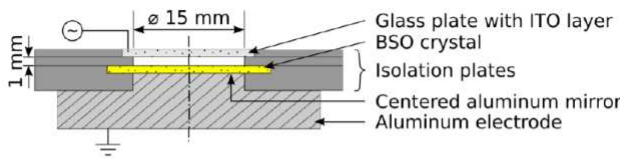


T. Hoder et al., prep. Appl. Phys. Lett.





Surface charge measurements

The discharge cell




- surface charge measurement on dielectric \Rightarrow utilization of the optoelectronic Pockels-effect \Rightarrow BSO-crystal ($\text{Bi}_{12}\text{SiO}_{20}$)
- E-field causes anisotropy of the crystal induced by **applied voltage** and **surface charges**






M. Bogaczyk, H.-E. Wagner, Uni. Greifswald




Summary

- Fast optical and spectroscopic methods = powerful tools for discharge diagnostics
- CCS as high sensitive method for spectroscopic investigation
 - \rightarrow Microdischarge development with high resolution ($\Delta t, \Delta x, \Delta \lambda$)
 - \rightarrow Estimation of plasma parameters ($E/n; \tau_{\text{eff}}, n_e/n_{e,\text{max}}$)
- Microdischarge development in barrier discharges:
 - (1) Townsend-prephase
 - (2) cathode directed ionization front (pos. streamer)
 - (3) decay phase
- Quantified determination of positive and negative surface charges by Pockels-effect
 - \rightarrow positive and negative surface charge density profiles significantly different due to the electron mobility
 - \rightarrow positive and negative charges can exist simultaneously
 - \rightarrow memory-effect important for discharge re-ignition



Outlook




Finished

- E/n-calibration of CCS device for systematic determination of plasma parameters (corona discharge)

Future work:

- To correlate fast spectroscopic and optical investigation with measurements of surface charges
 - structure and development (diffuse vs. filamentary)
 - role of surface processes (e.g. exoemission)
- Study of the correlation between plasma physics and chemistry
 - “From the microdischarge to the plasmareactor”



Acknowledgement



- University of Greifswald:
H.-E. Wagner, F. Miethke, J. Meichsner,
M. Bogaczyk, R. Wild, L. Stollenwerk
- Lomonossov University Moscow:
K.V. Kozlov, A.M. Morozov
- INP Greifswald:
T. Hoder, H. Grosch, R. Basner, W. Reich,
J. Schäfer, T. Gerling, R. Bussiahn, E. Kindel,
M. Kettlitz, H. Höft, K.-D. Weltmann
- Masaryk University Brno:
M. Cernak, D. Trunec, Z. Navratil, P. Stahel,
J. Janca, J. Jansky

Support:

- DFG: TR 24 “Fundamentals of complex plasmas”
- BMBF: “ForMaT - InnoPlas”









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